

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	§	Attorney Docket No. HSJ920030074US1
Michael W. Chaw	§	
	§	
Serial No.: Not yet assigned	§	Examiner: Unknown
	§	
Filed: Herewith	§	
	§	
For: System, Method, and Apparatus for	§	Art Unit: Unknown
Multilevel UV Molding Lithography for	§	
Air Bearing Surface Patterning	§	
	§	
	§	

INFORMATION DISCLOSURE STATEMENT
PURSUANT TO 37 C.F.R. § 1.97(b)

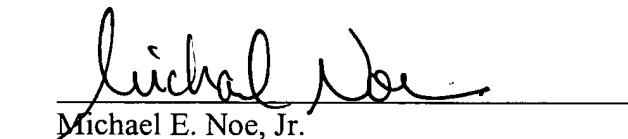
Commissioner for Patents
PO Box 1450
Alexandria, Virginia 22313-1450

Sir:

Applicants request that the information listed on the attached (Substitute) Form PTO-1449 be considered by the Office during the pendency of the above-entitled application, pursuant to 37 C.F.R. § 1.97. This Information Disclosure Statement is being filed under 37 C.F.R. § 1.97 (b) within three months of the filing date of the application, or before the mailing date of a first office action on the merits. No fee or certification is required.

No fee is believed to be necessary; however, in the event that any fee is required, please charge it to **HITACHI Global Storage Technologies Deposit Account Number 50-2587**.

Respectfully submitted,



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Substitute form 1449/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT				Complete if Known	
				Application Number	Not assigned
				Filing Date	Herewith
				First Named Inventor	Michael W. Chaw et al.
				Group Art Unit	Unknown
				Examiner Name	Unknown
Sheet	1	of	2	Attorney Docket Number	HSJ920030074US1

U.S. PATENT DOCUMENTS				
Examiner Initials	IDS Doc #	U.S. Patent Document Number	Name of Patentee or Applicant	Publication Date MM-DD-YYYY
	AA	6,503,406 B1	Hsiao et al.	01-07-2003
	AB	2002/0089787 A1	Lu et al.	07-11-2002
	AC	2002/0008078 A1	Hatamura et al.	01-24-2002
	AD	6,309,580 B1	Chou	10-30-2001
	AE	6,088,908	Imamura et al.	07-18-2000
	AF	6,061,897.	Shouji et al.	05-16-2000
	AG	6,004,472	Dorius et al.	12-21-1999
	AH	5,895,582	Wilson et al.	04-20-1999
	AI	5,853,959	Brand et al.	12-29-1998
	AJ	5,817,242	Biebuyck et al.	10-06-1998
	AK	5,768,055	Tian et al.	06-16-1998
	AL	5,567,333	Hira et al.	10-22-1996
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	AN	4,564,585	Blaske et al.	01-14-1986
	AO	654,867	J. Baker	07-31-1900

FOREIGN PATENT DOCUMENTS						
Examiner Initials	IDS Doc #	Office	Foreign Patent Document No.	Name of Patentee or Applicant	Date of Publication	English Translation
	AP	EP	1 072 954 A2	Lucent Technologies	01-31-2001	Yes
	AQ	JP	2001035112	Hitachi Ltd.	02-09-2001	Yes – abstract only
	AR	JP	2001006142	Matsushita Electric	01-12-2001	Yes – abstract only
	AS	JP	11061447	Citizen Watch Co.	03-05-1999	Yes – abstract only
	AT	JP	10289424	Citizen Watch Co.	10-27-1998	Yes – abstract only
	AU	JP	10064213	TDK Corp.	03-06-1998	Yes – abstract only

OTHER PRIOR ART – NON PATENT LITERATURE DOCUMENTS			
Examiner Initials	IDS Doc #	Include the name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	English Translation
	AV	IBM Technical Disclosure Bulletin; <i>Patterned Substrate for Improved Slider Fabrication</i> ; October 1993, pp. 409-410	
Examiner Signature			Date Considered

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.